APR 14 7006 B Docket No.: 055071-0267 PATENT

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Customer Number: 20277

Stephen D. HSU, et al. : Confirmation Number: 9799

Application No.: 10/626,858 : Group Art Unit: 2825

Filed: July 25, 2003 : Examiner: PARIHAR, Suchin

For: ORIENTATION DEPENDENT SHIELDING FOR USE WITH DIPOLE ILLUMINATION

**TECHNIQUES** 

## INFORMATION DISCLOSURE STATEMENT

Mail Stop Information Disclosure Statement Honorable Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed more than three months after the U.S. filing date AND after the mailing date of the first Office Action on the merits, but before the mailing date of a Final Rejection or Notice of Allowance.

To the extent necessary, a petition for an extension of time under 37 C.F.R. 1.136 is hereby made. Please charge any shortage in fees due in connection with the filing of this paper,

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## 10/626,858

including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

McDERMOTT WILL & EMERY LLP

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Facsimile: 202.756.8087 **Date: April 14, 2006** 

SHEET <u>1</u> OF <u>1</u>

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					APPLICANT Stephen D. HSU, et al.				
(PTO-1449)					FILING DATE July 25, 2003	ROUP <b>825</b>			
			U	S. PATEN	T DOCUMENTS				
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			EP 1 152 289 A3	11-07-2001				Х	
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		L	OTHER A	PT (Including Autho	Title Date Pertinent Pages E	to )			
EXAMINER'S INITIALS	CITE NO.	OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)  Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.  "Mask Topography Effects in Projection Printing of Phase-Shifting Masks", Alfred K. Wong and Andrew R. Neureuther, Fellow, IEEE Transactions on Electron Devices, Vol. 41, No. 6, June 1994  "Spatial Frequency Doubling Lithography (SFDL) of Periodic Structures for Integrated Optical Circuit Technology", Tanya E.							е,
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		EXA	MINER			DATE CONS	SIDERED		

<sup>\*</sup>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.